

Title (en)

Apparatus for electrochemical deposition of a metal

Title (de)

Vorrichtung zur elektrochemischen Abscheidung eines Metalls

Title (fr)

Appareil de dépôt électro-chimique d'un métal

Publication

**EP 2548998 A1 20130123 (EN)**

Application

**EP 11174683 A 20110720**

Priority

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Abstract (en)

The invention as described in the following relates to an apparatus for the electrochemical deposition of a metal on a substrate, which apparatus is capable of refreshing an electrolyte used for the deposition in a continuous way. Furthermore, the invention as described relates to a method of refreshing an electrolyte for the electrochemical deposition of a metal on a substrate.

IPC 8 full level

**C25D 21/18** (2006.01); **C25D 17/12** (2006.01); **C25D 21/14** (2006.01); **C25D 3/54** (2006.01)

CPC (source: EP US)

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Citation (applicant)

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